

IN THE CLAIMS:

Please substitute the pending claims with the following claims:

1. An electrostatic chuck comprising:
 - (a) a dielectric member comprising:
 - (i) a first layer comprising a semiconductive material having a resistivity of from about $5 \times 10^9 \Omega \text{ cm}$ to about $8 \times 10^{10} \Omega \text{ cm}$; and
 - (ii) a second layer ~~over the first layer, the second layer~~ comprising an insulative material having a resistivity of from about 1×10^{11} to about $1 \times 10^{20} \Omega \text{ cm}$; and
 - (b) an electrode in the first layer of the dielectric member.
2. (Cancel).
3. (Cancel).
4. (Cancel).
5. An electrostatic chuck according to claim 1 wherein the first layer comprises Al_2O_3 .
6. An electrostatic chuck according to claim 1 wherein the first layer comprises TiO_2 .
7. An electrostatic chuck according to claim 1 wherein the first layer comprises AlN .
8. (Cancel).

9. An electrostatic chuck according to claim 1 wherein the second layer comprises AlN.

10. An electrostatic chuck according to claim 1 wherein the second layer comprises SiO₂ or ZrO₂.

11. An electrostatic chuck according to claim 1 wherein the second layer comprises polyimide or Teflon®.

12. An electrostatic chuck according to claim 1 wherein the dielectric member is fabricated by sintering ceramic powders.

13. An electrostatic chuck comprising:

(a) a dielectric member comprising:

(i) a first layer comprising a resistivity of from about 5 x 10⁹ Ω cm to about 8 x 10¹⁰ Ω cm; and

(ii) a second layer ~~over the first layer, the second layer~~ comprising a resistivity of from about 1 x 10¹¹ to about 1 x 10²⁰ Ω cm; and

(b) an electrode in the first layer of the dielectric member.

14. An electrostatic chuck according to claim 13 wherein the first layer comprises Al₂O₃.

15. An electrostatic chuck according to claim 13 wherein the first layer comprises TiO₂.

16. (Cancel).

17. An electrostatic chuck according to claim 13 wherein the second layer comprises SiO₂.

18. An electrostatic chuck according to claim 13 wherein the second layer comprises ZrO_2 .

19. An electrostatic chuck comprising:

(a) a dielectric member comprising:

(i) a first semiconductive layer having a resistivity of from about $5 \times 10^9 \Omega \text{ cm}$ to about $8 \times 10^{10} \Omega \text{ cm}$ and that is sufficiently low to provide (i) a charging time of less than about 3 seconds, and (ii) allow accumulated electrostatic charge to substantially dissipate in less than about 1 second; and

(ii) a second insulative layer ~~over the first semiconductive layer, the second insulative layer~~ having a resistivity higher than the first semiconductive layer and from about 1×10^{11} to about $1 \times 10^{20} \Omega \text{ cm}$; and

(b) an electrode embedded in the first semiconductive layer of the dielectric member.

20. (Cancel).

21. (Cancel).

22. An electrostatic chuck according to claim 19 wherein the first semiconductive layer comprises Al_2O_3 .

23. (Cancel).

24. An electrostatic chuck according to claim 19 wherein the second insulative layer comprises SiO_2 .

25. An electrostatic chuck according to claim 19 wherein the second insulative layer comprises ZrO_2 .